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Leti

devices • workshop

December 8, 2013 | The Churchill Hotel, Washington D.C.

Inventing the future together

“a stimulating discussion of our vision for silicon nano-technologies in the next 10 years”

followed by a networking cocktail

On December 8, 2013 | Washington D.C.

6-9 p.m. / The Churchill Hotel - 1914 Connecticut Ave NW (across from the Hilton)



Introduction – 10 min.

Jean-René Lequepeys
VP Silicon Components Division



Lithography cost-effective solutions for 1X nodes – 15 min.

Serge Tedesco
Lithography Program Manager



3D: Dream and reality – 15 min.

Patrick Leduc
3D Program Manager



High-performance and reliable resistive memories embedded in advanced logic CMOS technologies – 15 min.

Barbara de Salvo
Advanced Memories Fellow



M&NEMS platforms : an enabler for the next generation of sensors in consumer electronics – 15 min.

Hugues Metras
VP Strategic Partnerships, North America



CMOS technologies: our most power efficient solution today and our vision toward 10nm node and beyond– 15 min.

Maud Vinet
Advanced CMOS Manager